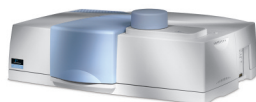


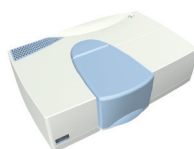
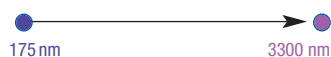
Technical Specifications for the LAMBDA 1050 UV/Vis/NIR and LAMBDA 950 UV/Vis/NIR Spectrophotometers



LAMBDA 1050

Choose the LAMBDA 1050 with its triple detector capability for ultra-high UV/Vis/NIR performance for wavelengths up to 3300 nm with extreme sensitivity in the NIR region (800-2500 nm) and higher energy throughput. For applications such as highly reflective and anti-reflective coatings, all types of glass from clear to highly absorbing safety glass, optical filters of all types from the deep UV through the NIR and many more applications requiring the best photodynamic range and the widest possible sampling capability.

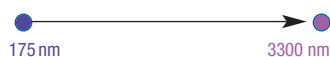
UV-Vis-NIR



LAMBDA 950

Choose the LAMBDA 950 for ultra-high UV/Vis/NIR performance for wavelengths up to 3300 nm, high-precision measurements, and for applications such as highly reflective and anti-reflective coatings, color correction coatings, bandpass characteristics of UV, Vis and NIR filters, and more.

UV-Vis-NIR



Introduction

PerkinElmer® UV/Vis and UV/Vis/NIR spectrophotometers are built to the highest ISO-9001 manufacturing standards. This document presents confirmed performance specifications based on factory tests.

All instruments will meet or achieve better than the confirmed specifications, under normal conditions of use as described in the user manual.

The LAMBDA™ Series of spectrophotometers is the industry standard for high performance, flexibility and convenience. Each model includes the same range of modular components and snap-in accessories to tackle a range of tough applications. Whatever specifications you require, the LAMBDA Series provides best-in-class accuracy, precision and reproducibility.

Technical description and specifications

LAMBDA 1050

LAMBDA 950

Principle

Double beam, double monochromator, ratio recording UV/Vis/NIR spectrophotometers with microcomputer electronics, controlled by DELL™ PC or compatible personal computer.

**Technical description
and specifications****LAMBDA 1050****LAMBDA 950**

Optical System	All reflecting optical system (SiO ₂ coated) with holographic grating monochromator with 1440 lines/mm UV/Vis blazed at 240 nm and 360 lines/mm NIR blazed at 1100 nm, Littrow mounting, sample thickness compensated detector optics.	
Beam Splitting System	Chopper (46+ Hz, Cycle: Dark/Sample/ Dark/Reference, Chopper Segment Signal Correction).	
Detector	Photomultiplier R6872 for high energy in the entire UV/Vis wavelength range. Combination of high performance Peltier-cooled InGaAs detector, 2 options: Narrow band covering 860-1800 or wide band covering 860-2500 nm and Peltier-cooled PbS detector for 1800/2500-3300 nm in the NIR wavelength range.	Photomultiplier R6872 for high energy in the entire UV/Vis wavelength range. High performance Peltier-cooled PbS detector for the NIR wavelength range.
Source	Pre-aligned tungsten-halogen and deuterium. Utilizes a source doubling mirror for improved UV/Vis/NIR energy.	Pre-aligned tungsten-halogen and deuterium.
Wavelength Range N ₂ purge required below 185 nm	175 nm - 3300 nm	175 nm - 3300 nm
UV/Vis Resolution	≤ 0.05 nm	≤ 0.05 nm
NIR Resolution	≤ 0.20 nm	≤ 0.20 nm
Stray Light		
At 200 nm 12 g/l KCl USP/DAP method	> 2 A	> 2 A
At 220 nm 10 g/l NaI ASTM method	≤ 0.00007 %T	≤ 0.00007 %T
At 340 nm 50 mg/l NaNO ₂ ASTM method	≤ 0.00007 %T	≤ 0.00007 %T
At 370 nm 50 mg/l NaNO ₂ ASTM method	≤ 0.00007 %T	≤ 0.00007 %T
At 1420 nm H ₂ O 1 cm path length	≤ 0.00040 %T	≤ 0.00040 %T
At 2365 nm CHCl ₃ 1 cm path length	≤ 0.00050 %T	≤ 0.00050 %T
Wavelength Accuracy		
UV/Vis	± 0.080 nm	± 0.080 nm
NIR	± 0.300 nm	± 0.300 nm
Wavelength Reproducibility		
UV/Vis (Deuterium lamp lines)	≤ 0.010 nm	≤ 0.020 nm
NIR (Deuterium lamp lines)	≤ 0.040 nm	≤ 0.080 nm
Standard deviation of 10 measurements UV/Vis	≤ 0.005 nm	≤ 0.005 nm
Standard deviation of 10 measurements NIR	≤ 0.020 nm	≤ 0.020 nm

Technical description and specifications	LAMBDA 1050	LAMBDA 950
Photometric Accuracy		
Double Aperture Method 1 A	± 0.0003 A	± 0.0006 A
Double Aperture Method 0.5 A	± 0.0003 A	± 0.0003 A
NIST 1930D Filters 2 A	± 0.0030 A	± 0.0030 A
NIST 930D Filters 1 A	± 0.0030 A	± 0.0030 A
NIST 930D Filters 0.5 A	± 0.0020 A	± 0.0020 A
K ₂ Cr ₂ O ₇ -Solution USP/DAP method	± 0.0080 A	± 0.0080 A
Photometric Linearity		
Addition of filters UV/Vis at 546.1 nm, 2 nm slit, 1 second integration time		
At 1.0 A	± 0.0060 A	± 0.0060 A
At 2.0 A	± 0.0160 A	± 0.0170 A
At 3.0 A	± 0.0050 A	± 0.0200 A
NIR At 1.0 A (1200 nm)	± 0.0005 A	
NIR At 2.0 A (1200 nm)	± 0.0010 A	
Photometric Reproducibility		
Standard deviation for 10 measurements, 2 nm slit, 1 second integration time		
1 A with NIST 930D Filter at 546.1 nm	≤ 0.00016 A	≤ 0.00016 A
0.5 A with NIST 930D Filter at 546.1 nm	≤ 0.00008 A	≤ 0.00008 A
0.3 A with NIST 930D Filter at 546.1 nm	≤ 0.00008 A	≤ 0.00008 A
Photometric Range		
UV/Vis	8 A	8 A
NIR	8 A	6 A
Photometric Display		
	Unlimited	Unlimited
Bandpass		
	0.05 nm - 5.00 nm in 0.01 nm increments UV/Vis range	
	0.20 nm - 20.00 nm in 0.04 nm increments NIR range	
	Fixed resolution, constant energy or slit programming.	
Photometric Stability		
After warm-up at 500 nm, 0 A, 2 nm slit, 2 second integration time, peak to peak		
	≤ 0.0002 A/h	≤ 0.0002 A/h
Baseline Flatness		
190 nm - 3100 nm, 2 nm slit		
0.20 second integration time		
UV/Vis, no smoothing applied	± 0.0008 A	± 0.0008 A
0.24 second integration time		
NIR, no smoothing applied		

**Technical description
and specifications****LAMBDA 1050****LAMBDA 950****Photometric Noise RMS**

2 nm slit, 1 second integration time

0 A and 190 nm	≤ 0.00010 A	≤ 0.00010 A
0 A and 500 nm	≤ 0.00005 A	≤ 0.00005 A
2 A and 500 nm	≤ 0.00020 A	≤ 0.00020 A
4 A and 500 nm	≤ 0.00100 A	≤ 0.00100 A
6 A and 500 nm	≤ 0.00500 A	≤ 0.00500 A
0 A and 1500 nm	≤ 0.00002 A	≤ 0.00004 A
2 A and 1500 nm	≤ 0.00010 A	≤ 0.00010 A
3 A and 1500 nm, PbS (Servo)	≤ 0.00250 A	≤ 0.00300 A
0 A and 1500 nm InGaAs	≤ 0.00002 A	
2 A and 1500 nm InGaAs	≤ 0.00010 A	
3 A and 1500 nm, Wide Band InGaAs (Servo)	≤ 0.00010 A	
3 A 1500 nm, Narrow Band InGaAs (Servo)	≤ 0.000025 A	

Primary Sample Compartment**Dimensions (W x D x H)** 200 mm x 300 mm x 220 mm 200 mm x 300 mm x 220 mm**Secondary Sample Compartment****Dimensions (W x D x H)** 480 mm x 300 mm x 220 mm 480 mm x 300 mm x 220 mm**Purging**

Optics	YES	YES
Sample Compartment	YES	YES

Instrument Dimension**(W x D x H)** 1020 mm x 740 mm x 300 mm 1020 mm x 740 mm x 300 mm**Instrument Weight**

~ 77 kg ~ 77 kg

Digital I/O

RS 232 C RS 232 C

Light Beam

90 mm above the base plate, 120 mm beam separation, 3 mm - 12 mm beam height

Instrument Requirements

Power	90 VAC - 250 VAC, 50/60 Hz; 250 VA	90 VAC - 250 VAC, 50/60 Hz; 250 VA
Temperature	10 °C - 35 °C	10 °C - 35 °C
Recommended Humidity	10-70% relative humidity, non-condensing	10-70% relative humidity, non-condensing

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